

<b>INFORMATION DISCLOSURE STATEMENT</b>  <b>PTO-1449</b>	ATTY. DOCKET NO. <b>NSL-022</b>	SERIAL NO. 10/771,092
	APPLICANT Brian M. Sager, et al.	
	FILING DATE: 2/2/04	GROUP:
<b>SHEET 1 OF 2</b>		

EXAMINER INITIAL	CITE NO.	DOCUMENT NUMBER	DATE	NAME
	<b>1</b>	<u>7511217</u>	03-2009	Roscheisen
	<b>2</b>	<u>6987071</u>	01-2006	Bollman

EXAMINER'S INITIALS	CITE NO.	PATENT NO.	PUBLICATION DATE MM-DD-YYYY	NAME OF PATENTEE	Translation	
					YES	NO
	<b>3</b>	2741954	03-1979	DE		
	<b>4</b>	200077691	03-2000	JP		
	<b>5</b>	WO 02/084708	10-2002	WO		

#### NON-PATENT LITERATURE DOCUMENTS

EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of article, title of item (book, journal , serial, etc...), date, pages, volume issue number, publisher, city/state where published	Translation	
			YES	NO
	<b>6</b>	PIERSON, et al. (Handbook of Chemical Vapor Deposition (CVD): Principles, Technology, and Applications, William Andrew Publishing, New York, USA, Copyright 1999, p. 310. cited by examiner .		
	<b>7</b>	D. ZHAO et al. "Triblock Copolymer Syntheses of Mesoporous Silica with Periodic 50 to 300 Angstrom Pores", Science, 279, 548-552. (1998). cited by other .		
	<b>8</b>	R. RYOO et al. "Block-Copolymer-Templated Ordered Mesoporous Silica: Array of Uniform Mesopores or Mesopore-Micropore Network?" J. Phys. Chem. B. 104, 11465-11471. (2000). cited by other .		
	<b>9</b>	M.H. HUANG et al. "Catalytic Growth of Zinc Oxide Nanowires by Vapor Transport" Adv. Mater. 13, 113-116 (Jan. 2001). cited by other .		
	<b>10</b>	U.S. Appl. No. 10/338,079 to Martin R. Roscheisen et al., filed on Jan. 6, 2003 and entitled "Nanostructured Transparent Conducting Electrode". cited by other.		
	<b>11</b>	Merriam Webster Online Dictionary entry for "template" [online], [retrieved on Jul. 16, 2004]. Retrieved from the Internet ,<URL: http://www.m-w.com/cgi-bin/dictionary?book=Dictionary&va=template>..		
	<b>12</b>	Merriam Webster Online Dictionary entry for "particulate" [online], [retrieved on Jun. 9, 2004]. Retrieved from the Internet ,<URL: http://www.m-w.com/cgi-bin/dictionary?book=Dictionary&va=particulate>..		
	<b>13</b>	Office Action from U.S. Patent Ser. No. 10/443,456		
	<b>14</b>	FINAL Office Action of May 25, 2004 for Ser. No. 10/319,406		
	<b>15</b>	NON-FINAL Office Action of May 25, 2004 for Ser. No. 10/319,406		
	<b>16</b>	INTERVIEW SUMMARY of July 23, 2004 for Ser. No. 10/319,406		
	<b>17</b>	FINAL Office Action of Dec 15, 2006 for Ser. No. 10/303,665		

EXAMINER	DATE CONSIDERED
----------	-----------------

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

<b>INFORMATION DISCLOSURE STATEMENT</b>  <b>PTO-1449</b>	ATTY. DOCKET NO. <b>NSL-022</b>	SERIAL NO. 10/771,092
	APPLICANT Brian M. Sager, et al.	
	FILING DATE: 2/2/04	GROUP:
<b>SHEET 2 OF 2</b>		

EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of article, title of item (book, journal , serial, etc...), date, pages, volume issue number, publisher, city/state where published	Translation	
			YES	NO
	<b>18</b>	NON-FINAL Office Action of June 29, 2006 for Ser. No. 10/303,665		
	<b>19</b>	NON-FINAL Office Action of Mar. 31, 2006 for Ser. No. 10/303,665		
	<b>20</b>	NON-FINAL Office Action of Oct. 20, 2005 for Ser. No. 10/303,665		
	<b>21</b>	INTERVIEW SUMMARY of June 5, 2007 for Ser. No. 10/290,119		
	<b>22</b>	ADVISORY ACTION of Oct. 12, 2006 for Ser. No. 10/290,119		
	<b>23</b>	FINAL Office Action of July 27, 2006 for Ser. No. 10/290,119		
	<b>24</b>	NON-FINAL Office Action of Dec. 14, 2005 for Ser. No. 10/290,119		
	<b>25</b>	NON-FINAL Office Action of May 31, 2007 for Ser. No. 10/771,250		
	<b>26</b>	FINAL Office Action of Dec. 13, 2007 for Ser. No. 10/771,250		

EXAMINER	DATE CONSIDERED
----------	-----------------

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.